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Docket No.: 51166

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT: Cameron et al.

EXAMINER: R. Ashton

SERIAL NO.: 09/930,880

GROUP: 1752

FILED: August 15, 2001

FOR: PHOTORESIST COMPOSITIONS

ASSISTANT COMMISSIONER FOR PATENTS  
WASHINGTON, D.C. 20231

Sir:

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AMENDMENT

Applicants are in receipt of the Office Action of November 26, 2002. Please amend the above-identified application as follows.

**IN THE CLAIMS**

Please cancel claims 1-32 without prejudice.

Please add the following new claims.

33. A chemically-amplified positive photoresist composition comprising 1) a resin, 2) a photoacid generator compound, and 3) lactic acid or acetic acid.

34. The photoresist of claim 33 wherein the lactic acid or acetic acid is present in an amount of at least about 0.5 weight percent based on total solids of the photoresist composition.

35. The photoresist of claim 33 wherein the lactic acid or acetic acid is present in an amount of at least about 0.8 weight percent based on total solids of the photoresist composition.

36. The photoresist of claim 33 wherein the lactic acid or acetic acid is present in an amount of at least about 1 weight percent based on total solids of the photoresist composition.